

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(Not for submission under 37 CFR 1.99)

Application Number	10/559,615
Filing Date	December 2, 2005
First Named Inventor	Youichi NANBA
Art Unit	1795
Examiner Name	Tony Sheng Hsiang CHUO
Attorney Docket Number	Q76011

U.S. PATENTS

Examiner Initials*	Cite No	Patent Number	Kind Code ¹	Issue Date	Name of Patentee or Applicant of cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
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EXAMINER SIGNATURE

Examiner Signature	/Tony Chuo/ (10/20/2009)	Date Considered	
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